

Special Issue

Advanced Oxidation Processes for Water Treatment

Message from the Guest Editors

This Special Issue aims to present recent findings in the process of trying to increase the AOPs efficacy and to suite them to be used in real water/wastewater treatment plants. Potential topics include but are not limited to:

- ozone based processes (with or without H₂O₂)
- UV-based processes (with or without H₂O₂)
- photocatalytic processes (UV or visible light driven)
- Fenton or Photo-Fenton processes
- ultrasound based processes
- persulfate oxidation processes (heat, UV, Fe(II))
- electric discharge processes
- ionizing radiation processes
- pulsed plasma processes

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About the Journal

Message from the Editor-in-Chief

As the world of science becomes ever more specialized, researchers may lose themselves in the deep forest of the ever increasing number of subfields being created. This open access journal *Applied Sciences* has been started to link these subfields, so researchers can cut through the forest and see the surrounding, or quite distant fields and subfields to help develop his/her own research even further with the aid of this multi-dimensional network.

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